

OPEN

Received: 24 January 2018 Accepted: 12 October 2018 Published online: 29 October 2018

L1₀-FeNi films on Au-Cu-Ni buffer-layer: a high-throughput combinatorial study

G. Giannopoulos¹, G. Barucca⁰², A. Kaidatzis¹, V. Psycharis¹, R. Salikhov^{3,4}, M. Farle^{3,5}, E. Koutsouflakis¹, D. Niarchos¹, A. Mehta⁶, M. Scuderi⁷, G. Nicotra⁷, C. Spinella⁷, S. Laureti⁸ & G. Varvaro⁸

The fct L1₀-FeNi alloy is a promising candidate for the development of high performance critical-elements-free magnetic materials. Among the different materials, the Au-Cu-Ni alloy has resulted very promising; however, a detailed investigation of the effect of the buffer-layer composition on the formation of the hard FeNi phase is still missing. To accelerate the search of the best Au-Cu-Ni composition, a combinatorial approach based on High-Throughput (HT) experimental methods has been exploited in this paper. HT magnetic characterization methods revealed the presence of a hard magnetic phase with an out-of-plane easy-axis, whose coercivity increases from 0.49 kOe up to 1.30 kOe as the Au content of the Cu-Au-Ni buffer-layer decreases. Similarly, the out-of-plane magnetocrystalline anisotropy energy density increases from 0.12 to 0.35 MJ/m³. This anisotropy is attributed to the partial formation of the L1₀ FeNi phase induced by the buffer-layer. In the range of compositions we investigated, the buffer-layer structure does not change significantly and the modulation of the magnetic properties with the Au content in the combinatorial layer is mainly related to the different nature and extent of interlayer diffusion processes, which have a great impact on the formation and order degree of the L1₀ FeNi phase.

The ferromagnetic equiatomic FeNi alloy with a face-centered tetragonal (fct) L10-type structure, also known as *tetrataenite*, is a promising candidate for the replacement of high-anisotropy magnetic materials containing rare-earths and critical elements $^{1-5}$ due to its excellent intrinsic magnetic properties, such as large saturation magnetization (~1.6 T), high uniaxial magneto-crystalline anisotropy (MCA~1 MJ/m³), fairly high Curie temperature (up to 550 °C) and low magnetization damping constant $^{6-8}$. The fabrication of the L10-FeNi phase is extremely challenging due to the low atomic mobility below the chemical order/disorder transition temperature (~320 °C) 9 that kinetically limits the formation of the L10 phase. This FeNi phase is naturally found in meteorites, where it forms over millions of years in extreme temperature/pressure conditions 6 . Different strategies have been proposed to artificially obtain the tetrataenite phase, including deposition of alternate Fe and Ni monoatomic layers $^{10-14}$, irradiation with neutrons or high energy electrons 15,16 , addition of a third element 7,16 or by exploiting the epitaxial strain induced by suitable templates in both thin films $^{13,17-20}$ and nanoparticles 2 1 systems.

The origin of the large magneto-crystalline anisotropy in $L1_0$ -FeNi and its relation to the strain effect has been extensively discussed. According to theoretical calculations, the MCA in $L1_0$ -FeNi systems can be predominantly attributed to the constituent Fe atoms and increases by decreasing the a/c axial ratio²² (a and c corresponding to the cubic in-plane and out-plane lattice constant). The predicted trend for the MCA energy is also in line with experimental studies, where tetragonal $L1_0$ -ordered FeNi films were stabilized using the alternate deposition of Fe and Ni monatomic layers²³. Furthermore, an extensive theoretical work has been done about phase stability²⁴, phase transformation, segregation effects²⁵ and coercivity improvement through nano-structuring in FeNi

¹Institute of Nanoscience and Nanotechnology, NCSR Demokritos, Athens, Greece. ²Università Politecnica delle Marche, Dipartimento SIMAU, Via Brecce Bianche 12, Ancona, 60131, Italy. ³Faculty of Physics and Center for Nanointegration (CENIDE), University of Duisburg-Essen, 47057, Duisburg, Germany. ⁴Zavoisky Physical-Technical Institute, FRC Kazan Scientific Center of RAS, 420029, Kazan, Russian Federation. ⁵Center for Functionalized Magnetic Materials (FunMagMa), Immanuel Kant Baltic Federal University, Kaliningrad, Russian Federation. ⁶SLAC National Accelerator Laboratory-Stanford University, Menlo Park, California, USA. ⁷IMM-CNR, VII strada 5, 95121, Catania, Italy. ⁸Istituto di Struttura della Materia, CNR, Monterotondo Scalo, Roma, Italy. Correspondence and requests for materials should be addressed to G.G. (email: q.qiannopoulos@inn.demokritos.qr) or G.B. (email: q.barucca@univpm.it)

alloys²⁶. Theoretical works support that structural parameters of the FeNi alloy significantly depend on the Fe/Ni ratio as the Young's modulus of the bcc Fe increases by enhancing the concentration of nickel²⁷.

By following the Bain path²⁸, metastable tetragonal phases can be stabilized by straining the unit cell²⁹. For the FeNi alloy, the tetragonal distortion can be induced via coherent growth of the film on different substrates (e.g. MgO (100)¹⁷ or Cu (001)¹⁸) or buffer-layers (Cu^{13,19}, Cu-Ni²⁰ and Au-Cu-Ni^{8,11,14}). Among them, the Au-Cu-Ni alloy has resulted very promising; however, a detailed investigation of the effect of the buffer-layer composition on the formation of the tetragonal phase is still missing.

To speed-up the search of the best Au-Cu-Ni composition, a combinatorial approach based on High-Throughput (HT) experimental methods has been exploited in this paper. HT techniques aim at fabricating materials libraries by creating ternary or quaternary compounds as candidate structures. On such a library, a well-defined set of materials with different chemical compositions is deposited in a single run, that means at a fraction of a time compared to conventional approaches. Data mining techniques³⁰ are then used for a robust and effective materials analysis³¹ to reinforce and accelerate the experimental search by identifying the most promising alloys' stoichiometry.

In this work, a Cu-Au-Ni compositional spread library was deposited as a buffer-layer by using a Combinatorial Sputtering Technique³² to tune the lattice constant and tailor the lattice mismatch with a FeNi film deposited on top in order to determine the best stoichiometry promoting the $L1_0$ -ordering. Magneto-Optic Kerr Effect (MOKE) analysis was used for a first screening of the FeNi magnetic properties. X-ray Fluorescence (XRF), Wide-angle X-ray Scattering (WAXS), Scanning Transmission Electron Microscopy (STEM), Energy Dispersive X-ray (EDX) microanalysis and Ferromagnetic Resonance (FMR) measurements were performed to investigate the structural, chemical and magnetic properties of selected samples.

Results and Discussion

Figure 1a reports on representative polar field-dependent magnetization loops collected at room temperature from selected areas on the wafer, corresponding to different nominal Au-Cu-Ni compositions measured by XRF (data provided in Supplementary Materials Section, Figure S1a-c). All the loops present a hysteretic feature superimposed to a linear M(H) contribution. The hysteretic behavior suggests the presence of a hard magnetic phase with an out-of-plane magnetic anisotropy. The linear contribution to the magnetization loops can be ascribed either to hard magnetic regions with the easy-axis pointing along different directions with respect to the normal to the film surface or to the presence of soft magnetic grains whose anisotropy lies in the film plane due to the demagnetizing fields.

As clearly shown in Fig. 1a, and schematically reported in Fig. 1b, the out-of-plane coercivity, extracted from the maximum in susceptibility evaluated by the field derivative of the hysteresis loop, increases by reducing the Au content from $H_C = 0.49 \, \text{kOe}$ (on $\text{Au}_{18.2} \text{Cu}_{40.0} \text{Ni}_{38.5}$) up to 1.3 kOe (on $\text{Au}_{13.4} \text{Cu}_{47.5} \text{Ni}_{44.7}$).

The significant change of H_C cannot be attributed to the film microstructure, as the surface morphology of the film, measured by AFM (data provided in Supplementary Materials Section, Figure S2) remains almost unchanged across the wafer. Moreover, being the MOKE technique only sensitive to the magnetization within the skin depth region of a film, typically 20–40 nm in most metals³³, the performed measurements are only sensitive to the FeNi layer (nominal thickness: 40 nm).

To disclose the effect of the buffer-layer composition on the magnetic properties of the FeNi layer, a thoroughly investigation of both the structural and microstructural properties have been performed on three selected samples with different out-of-plane coercivity (varying from 1.30 kOe in the high-coercivity region down to 0.49 kOe in the low-coercivity region) corresponding to three different nominal compositions of the combinatorial layer ($Au_{13.4}Cu_{47.5}Ni_{44.7}$, $Au_{14.8}Cu_{45.6}Ni_{39.6}$ and $Au_{18.2}Cu_{40.0}Ni_{38.5}$ respectively). Hereafter the three samples will be referred as H-FeNi, M-FeNi and L-FeNi, where H, M and L stand for high, medium and low coercivity, respectively.

Wide-angle X-ray Scattering (WAXS) has been employed to examine the structural properties of the samples (Fig. 2). Diffraction peaks attributed to the seed and Au capping layers are indicated along with the reflections corresponding to the $L1_0$ -FeNi phase 34,35 . The WAXS measurements were collected in grazing incidence geometry where the angle of incidence is fixed while the diffracted angle is varied (see the Supplementary Materials Section, Figs S3 and S4). In our diffraction geometry, the observed (001) $L1_0$ -FeNi peak probes grains for which the c-axis (corresponding to the magnetic easy-axis) forms a relatively small angle of 4° with respect to the perpendicular to the film surface thus justifying the observed hysteretic behaviour measured by the polar MOKE. The FeNi (111) reflection peak cannot be univocally assigned to the $L1_0$ -phase (a contribution from the chemical disordered FeNi phase cannot be excluded); however, the possible presence of (111) and (011) $L1_0$ -FeNi grains would also give rise to a contribution to the magnetic behaviour along the normal to the film plane, being the corresponding c-axis, in both the cases, tilted away from the film surface (see the Supplementary Materials Section). Moreover, the presence of such hard magnetic grains with a tilted easy-axis along with a fraction of soft magnetic grains, can explain the observed linear contribution to the polar MOKE magnetization loops.

It must be stressed the absence of peaks due to the CuAuNi combinatorial layer, suggesting a lattice matching between the Cu_3Au seed-layer and the overlying combinatorial layer independently of its composition. Furthermore, the presence of a single diffraction peak related to the seed-layer indicates that the chemical ordered Cu_3Au phase (ICDD n° 351357) is highly textured.

To further investigate the structure of the samples, STEM analyses were conducted in the high- and low-coercivity regions of the wafer (samples *H*-FeNi and *L*-FeNi, respectively). Fig. 3a shows a high-angle annular dark field (HAADF) STEM image of sample *H*-FeNi. The film shows an islands structure (in agreement with the AFM images), and it is not possible to distinguish the Cu₃Au seed-layer from the combinatorial Au-Cu-Ni layer inside the islands. To investigate the nature of the combinatorial layer, atomic resolution HAADF-STEM (HR-HAADF STEM) observations were performed. In detail, Fig. 3b shows the atomic structure of the Cu₃Au

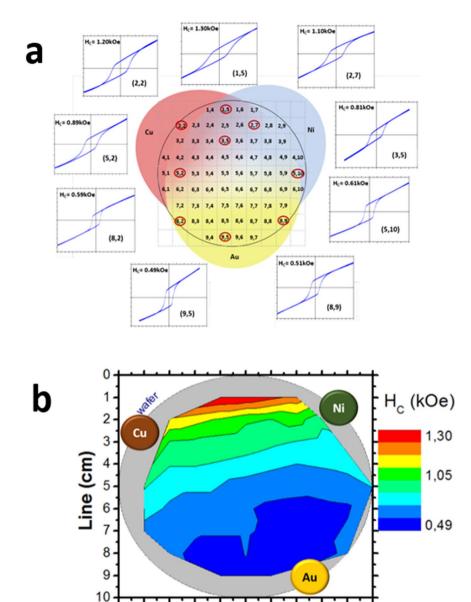


Figure 1. (a) Representative room temperature polar field-dependent magnetization loops showing the systematic change of the coercivity (H_C) with the Au-Cu-Ni stoichiometry. (b) Color-coded coercive field diagram; the numbers (X, Y) identify the measured areas on the wafer corresponding to different Au-Cu-Ni compositions. The applied magnetic field range of the hysteresis loops is $\pm 5\,\mathrm{kOe}$.

3 4 5 6 7 Column (cm)

phase in the <111> zone axis. Due to the typical Z-contrast (atomic number contrast) of the technique, gold atoms appear brighter than copper ones. A representative portion of the combinatorial layer is shown at the top side of Fig. 3c (circled area, white arrow). Atoms (white spots) have all the same contrast, revealing the absence of chemical order, and their distribution is compatible with a face centered cubic (fcc) phase in the <111> zone axis and lattice parameter $a=(3.69\pm0.04)$ Å. The transition region between the Cu₃Au layer (circled area, dark arrow) and the combinatorial layer is also visible in Fig. 3c. Atomic planes extend from one phase to the other without interruption (area between dark dotted lines) as occurs in epitaxial growth mechanisms. Considering the local nature of HR-HAADF STEM observations, the term "local epitaxy" will be used to describe this lattice matching in the rest of the paper. The FeNi layer is clearly visible at the top of the islands in Fig. 3a and it has a thickness of about 40 nm, in agreement with the deposition nominal value.

A HR-HAADF STEM image of the FeNi layer is shown in Fig. 3d. The atomic planes appear as white lines and their interplanar distance $d = (1.80 \pm 0.01)$ Å is compatible with the (002) planes of the FeNi phase. Interestingly, at the top-left corner it is possible to observe white alternating lines having different contrast (thin lines between large ones). This contrast variation of the lattice planes is compatible with the chemical order of the L1₀ FeNi phase in the [001] direction. On the other side of the image, the contrast is the same for all the lattice planes,

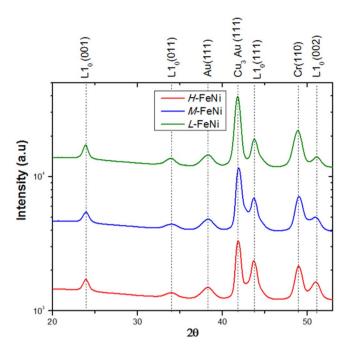


Figure 2. WAXS diffractograms of samples H-FeNi, M-FeNi and L-FeNi corresponding to different regions of the compositional spread materials library. The dashed lines indicate the reference peak positions for the different phases.

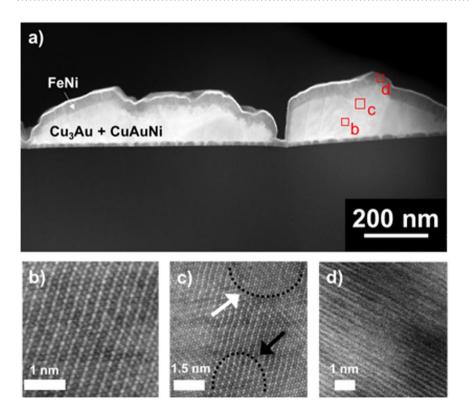


Figure 3. H-FeNi Sample. (a) HAADF-STEM image. (b), (c) and (d) HR-HAAFD STEM images of selected regions of the island in the <111> Cu₃Au zone axis.

indicating the absence of a chemical order³³. To further confirm the presence of the ordered FeNi phase, computer simulations of the HR-HAADF STEM image were performed by using the "jems" software³⁶. Results are shown in the Supplementary Materials Section (Figs S7 and S8) and confirm both the possibility to use atomic resolution Z-contrast to distinguish Fe and Ni atoms and the presence of the ordered FeNi phase associated to the alternating

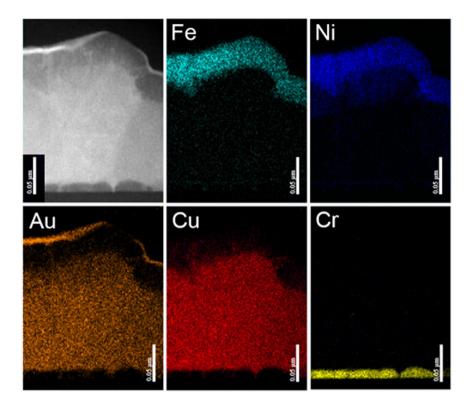


Figure 4. H-FeNi Sample. EDX compositional maps of the island area reported on the top-left corner.

lines having different contrast. Experimental and simulation results suggest the contemporary presence of chemical ordered and disordered phases in the FeNi layer.

EDX analysis was performed on a portion of the island at the right side of Fig. 3a. Distribution maps of the different elements and the island region investigated are shown in Fig. 4. From these images, it is possible to identify the different layers and the corresponding thicknesses are clearly inferable. It is important to note the presence of a slight diffusion of atomic species from the combinatorial to the FeNi layer. In particular, the brighter strips visible in the FeNi layer are associated to the presence of copper and gold atoms.

A HAADF-STEM image of sample L-FeNi is shown in Fig. 5a. Although the film is still composed of islands, however the inner structure results different. In particular, it is quite difficult to distinguish the FeNi layer from the combinatorial phase. The absence of contrast in transmission electron microscopy (data provided in Supplementary Materials Section, Figure S5) and HAADF-STEM mode suggests a local epitaxial growth between the two layers and a quite similar average atomic number. The structure of the combinatorial layer is evidenced by HR-HAADF STEM observations. As for the previous sample, the layer presents a face centred cubic (fcc) structure with a slightly smaller lattice parameter $a = (3.55 \pm 0.04)$ Å. Fig. 4b shows a typical HR-HAADF image of the combinatorial layer taken in the <110> zone axis orientation, which reveals the presence of a $\{111\}$ twin plane. The presence of these defects can be responsible for lattice planes rotation in the FeNi layer, and of the corresponding c-axis 37 .

HR-HAADF STEM images on the FeNi layer are reported in Fig. 5c,d. Two families of atomic planes are visible, the interplanar distances being $d=(1.26\pm0.01)$ Å and $d=(1.79\pm0.01)$ Å, compatible with the (022) and (002) planes of the FeNi phase, respectively. It must be stressed that in Fig. 5d the contrast of each visible plane is the same suggesting the absence in this specific region of the sample of any chemical order for the FeNi phase in the c-direction. However, the presence of the $L1_0$ -FeNi phase, as clearly shown in the WAXS spectra, cannot be excluded in other regions of the films. EDX analysis was performed on the island shown in Fig. 5a. The distribution map of the different elements and the island area investigated are shown in Fig. 6. From the EDX maps it is possible to identify the different layers and estimate their thickness. The presence of the diffusion processes from the combinatorial to the FeNi layer are clearly visible. In particular, the brighter strips, starting from the Cu_3Au seed-layer and arriving up to the top of the FeNi layer are very rich in Au and reveal diffusion and accumulation processes of gold through the layers. A small diffusion of Cu atoms in the FeNi layer is also present. Fe and Cu atoms are also visible at the bottom of the island, but their presence is due to the specific morphology of the sample and is attributed to superposition effect in the STEM image formation, being the STEM-EDX measurements a bi-dimensional projection of a three-dimensional structure.

WAXS and STEM measurements have shown a very complex structure of the samples by varying the gold composition of the combinatorial layer. In detail, the chemical ordered $L1_0$ -FeNi phase is present in all the samples regardless of the combinatorial layer stoichiometry, as evidenced by WAXS spectra. Indeed, electron microscopy analyses carried out on the H-FeNi and L-FeNi regions have shown the same face centered cubic (fcc) structure for the Cu-Au-Ni layer, which grows in a locally epitaxial way on the Cu₃Au seed-layer. Such locally

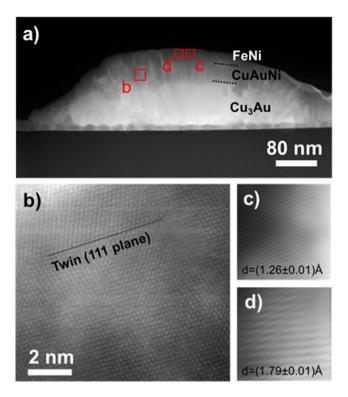


Figure 5. Sample L-FeNi sample. (a) HAADF-STEM image. (b), (c) and (d) HR-HAADF STEM images of the selected regions of the island in the <110> Cu₃Au zone axis.

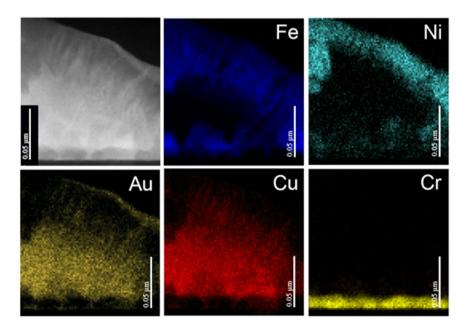


Figure 6. Sample L-FeNi sample. EDX compositional maps of the island area reported on the top-left corner.

epitaxial grow is suggested to cause a strain-driven diffusion of elements 38 during the deposition, which depends on the buffer-layer composition. The nature and extent of the diffusion processes determine the amount and likely the chemical order degree of the FeNi L1 $_0$ phase formed in the different samples, thus leading to different magnetic properties.

To get further insight into the magnetic properties of the samples, as a function of the Au content, ferromagnetic resonance (FMR) spectra of *H*-FeNi, *M*-FeNi and *L*-FeNi were recorded with the external magnetic field applied parallel to the film plane (Fig. 7). All the spectra show resonances at magnetic fields smaller than $\omega/\gamma = 336$ mT ($\omega = 2\pi\nu$, ν is the microwave frequency, $\gamma = g\mu_B/\hbar$ is the electron gyromagnetic ratio, g = 2.1 is the

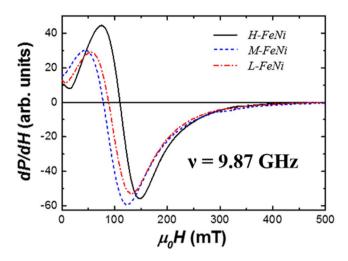


Figure 7. Derivative of FMR absorbed microwave power (P) as a function of the applied magnetic field for samples H-FeNi, M-FeNi and L-FeNi. All spectra were recorded at room temperature with the magnetic field applied parallel to the film plane.

spectroscopic splitting factor assumed for the ${\rm Fe_{50}Ni_{50}}^{39}$), thus indicating that the magnetization easy axis preferentially lies in the film plane due to the larger contribution of magnetic shape anisotropy in FeNi films^{40,41}. The in-plane angular dependent measurements do not reveal any magnetic anisotropy with axial symmetry lying in the film plane. From the analysis of the measured resonance fields (H_r) in the in-plane geometry (Fig. 7) we find that the equilibrium direction of magnetization is parallel to the applied magnetic field and the resonance conditions can be described very accurately using the Kittel equation as was shown elsewhere⁴²:

$$\left(\frac{\omega}{\gamma}\right)^2 = \mu_0^2 H_{\rm r} (H_{\rm r} + M_{\rm eff}),\tag{1}$$

where $\mu_0 M_{eff} = \mu_0 f M_s - 2 K_2 / M_s$ is the effective magnetization. The saturation magnetisation M_s as determined from magnetometry measurements, was found to be similar in all regions of the wafer ($\mu_0 M_s = 1500 \pm 100$ mT). A volumetric filling factor f = 0.97 (determined from the AFM images) was introduced in order to consider the granular structure of magnetic films⁴³. The parameter K_2 is used to account for the out-of-plane magneto-crystalline anisotropy energy density, which competes with the shape anisotropy of ferromagnetic films and favours the perpendicular alignment of the magnetization with respect to the film plane. In Fig. 7 it can be observed that the resonance field for the high coercive field region ($\mu_0 H_r = 110 \text{ mT}$) is larger than the corresponding for the low coercive field region ($\mu_0 H_r = 82 \text{ mT}$). This indicates that the perpendicular magnetic anisotropy (K_2) in the H-FeNi sample is larger than in M-FeNi and L-FeNi films, in line with the MOKE results. Using the equation (1) the estimated MCA energy density moves form $K_2 = 0.35 \pm 0.01$ MJ/m³ for the H-FeNi sample to $K_2 = 0.12 \pm 0.01$ MJ/m³ for the L-FeNi sample. In any case, the obtained MCA energy densities in all the samples are by two orders of magnitude larger than the values known for the cubic Fe₅₀Ni₅₀ alloy⁴⁴. The film thickness of 40 nm is large enough to exclude a significant interface contribution to the MCA^{29,40}. WAXS and HR-STEM analyses reveal the presence of the ordered L1₀-FeNi phase, which explains the relatively large MCA in all the samples. Remarkably, the MCA in the H-FeNi sample is comparable to the anisotropies reported for L1₀-ordered FeNi films stabilized using the alternate deposition of Fe and Ni mono-atomic layers 10,11. Smaller MCA in M-FeNi and L-FeNi samples suggests reduced chemical order degree of the L1₀-FeNi¹⁶ phase, which can be affected by the inter-diffusion processes.

Conclusion

A Cu-Au-Ni compositional spread library was deposited as buffer-layer to explore the effect of different compositions on the formation of the $\rm L1_0$ -FeNi phase. HT magnetic characterization methods revealed the presence of a hard magnetic phase with an out-of-plane anisotropy, whose coercivity, measured along the film normal, increases from approximately 0.5 kOe up to 1.3 kOe as the Au content of the Cu-Au-Ni buffer-layer decreases. Similarly, the out-of-plane magneto-crystalline anisotropy energy density increases from 0.12 to 0.35 MJ/m³, such large values being related to the formation of the $\rm L1_0$ FeNi phase induced by the buffer-layer. We remarkably observed that, in the range of compositions we investigated, the layers grow in a locally epitaxial way and a complex strain-driven diffusion mechanism, which depends on the Cu-Au-Ni atomic composition, was disclosed. Consequently, the great variation of the magnetic properties along the wafer surface can be mainly attributed to a strain-driven diffusion effect, strongly dependent on the stoichiometry of the buffer-layer, which is supposed to greatly influences the amount and/or the order degree of the $\rm L1_0$ -FeNi phase.

By exploiting the advantage of a combinatorial approach, our study allows providing guidelines for the preparation of the high anisotropy L1₀-FeNi phase; indeed, the results suggest that including a thin diffusion barrier

layer between the Au-Cu-Ni and the FeNi layers, by keeping the crystallographic texture while reducing or even avoiding the diffusion effect, would allow to fully exploit the potential of the Au-Cu-Ni alloy to obtain highly ordered FeNi $L1_0$ thin films.

Methods

Material Preparation. A high-vacuum AJA Int. ATC 2200-V magnetron sputtering system with a base pressure of 5×10^{-9} Torr was used to deposit on a 4-inch Si (100) substrate a Cr(10 nm)/AuCu₃(70 nm)/combi-Au-Cu-Ni/NiFe(40 nm) stack (the reported thicknesses are nominal), where the combi-Au-Cu-Ni buffer-layer is a compositional spread layer of various stoichiometries co-deposited using combinatorial sputtering. The thickness of the combinatorial was estimated at 50 nm at the center of the Si wafer. The rest of the layers have homogeneous composition and thickness. The final deposition of FeNi was performed by co-sputtering Fe and Ni to a stoichiometry of 50-50 at.%. The Cr and Cu₃Au seed-layers were deposited at 300 °C, while the combinatorial Au-Cu-Ni and Fe₅₀Ni₅₀ layers were grown at 200 °C; the Ar pressure was set at 3mTorr for all the layers.

Material Characterization. Room temperature magnetic properties were mapped across the wafer by using a High-Throughput polar magneto-optical Kerr effect (HT-MOKE) magnetometer with a maximum external magnetic field of 1.1 T. The spatial resolution, as determined from the laser spot size, is approximately 2 mm. Thin films' structure and microstructure were investigated by Scanning Transmission Electron Microscopy (STEM) techniques. A JEOL JEM-ARM200F microscope equipped with a microanalysis system EDS Centurio was used for STEM observations and Energy Dispersive X-ray (EDX) measurements. MCA energy density of selected sample areas was determined using a conventional Bruker X-band ferromagnetic resonance (FMR) spectrometer operating at a microwave frequency of $\nu=9.87$ GHz. FMR spectra were recorded, at room temperature for different orientations of the static magnetic field within the film plane (in-plane measurements). Wide Angle X-ray scattering (WAXS) and X-ray Fluorescence (XRF) measurements have been performed at beam-line (BL) 1–5 bending magnet end station, at the Stanford Synchrotron Radiation Laboratory (SSRL/SLAC). BL1–5 is equipped with a two dimensional Rayonix 165 CCD detector for X-ray diffraction analysis and a vortex detector for paralleled XRF analysis. The X-ray energy employed during experiments was 12.7 keV and the angle of incidence was 4°

References

- Cebollada A. et al. Ch. 3, Structure and Magnetic Properties of Chemically Ordered Magnetic Binary Alloys in Thin Film Form, in Magnetic Nanostructures, Ed. H.S. Nalwa, American Scientific Publishers, (2002).
- 2. Cui, J. et al. Current progress and future challenges in rare-earth-free permanent magnets. Acta Materialia 158, 118 (2018).
- 3. Coey, J. M. D. Hard Magnetic Materials: A Perspective. IEEE Trans. Magn. 47, 4671 (2011).
- 4. Edstrom, A. et al. Electronic structure and magnetic properties of L1₀ binary alloys. Phys. Rev. B 90, 014402 (2014).
- 5. Varvaro, G. et al. L1₀ FePt-based thin films for future perpendicular magnetic recording media. *JMMM* 368, 415 (2014).
- 6. Poirier, E. et al. Intrinsic magnetic properties of L1₀ FeNi obtained from meteorite NWA 6259. J. Appl. Phys 117, 17E318 (2015).
- 7. Kojima, T. et al. Addition of Co to L1₀-ordered FeNi films: influences on magnetic properties and ordered structures. J. Phys. D: Appl. Phys. 47, 425001 (2014).
- 8. Ogiwara, M. et al. Magnetization damping of an L10-FeNi thin film with perpendicular magnetic anisotropy. Appl. Phys. Lett. 103, 242409 (2013).
- 9. Kabanova, I. G., Sagaradze, V. V. & Kataeva, N. V. Formation of an L1 $_0$ superstructure in austenite upon the $\alpha \rightarrow \gamma$ transformation in the invar alloy Fe-32% Ni. *Phys. Met. Metall.* 112, 267 (2011).
- Shima, T., Okamura, M., Mitani, S. & Takanashi, K. Structure and magnetic properties for L1₀-ordered FeNi films prepared by alternate monatomic layer deposition. J. Magn. Magn. Magn. Magn. (2007).
- 11. Kojima, T. et al. Fe–Ni composition dependence of magnetic anisotropy in artificially fabricated L1₀-ordered FeNi films. *J. Phys.: Condens. Matter* **26**, 064207 (2014).
- Mizuguchi, M. Artificial Fabrication and Order Parameter Estimation of L1₀-ordered FeNi Thin Film Grown on a AuNi Buffer Layer. J. Magn. Soc. Jpn. 35, 370 (2011).
- 13. Mizuguchi, M., Sekiya, S. & Takanashi, K. Characterization of Cu buffer layers for growth of L1₀-FeNi thin films. *J. Appl. Phys.* **107**, 09A716 (2010).
- Kojima, T. et al. Magnetic Anisotropy and Chemical Order of Artificially Synthesized L1₀-Ordered FeNi Films on Au-Cu-Ni Buffer Layers. Jpn. J. Appl. Phys., Part 1(51), 010204 (2012).
- 15. Reuter, K. B., Williams, D. B. & Goldstein, J. I. Determination of the Fe-Ni phase diagram below 400 °C. Metall. Mater. Trans. A 20, 71 (1989).
- 16. Manchanda, P., Skomski, R., Bordeaux, N., Lewis, L. H. & Kashyap, A. Transition-metal and metalloid substitutions in L1₀-ordered FeNi. *J. Appl. Phys.* **115**, 17A710 (2014).
- 17. Myagkov, V. G., Bayukov, O. A., Bykova, L. E., Zhigalov, V. S. & Bondarenko, G. N. Solid-state synthesis in Ni/Fe/MgO(001) epitaxial thin films. *JETP Letters* 80(7), 487–490 (2004).
- Kojima, T., Mizuguchi, M. & Takanashi, K. Growth of L1₀-FeNi thin films on Cu(001) single crystal substrates using oxygen and gold surfactants. Thin Solid Films 603, 348-352 (2016).
- Frisk, A., Lindgren, B., Pappas, S. D., Johansson, E. & Andersson, G. Strain engineering for controlled growth of thin-film FeNi L1₀. J. Phys.: Condens. Matter 28, 406002 (9pp), (2016).
- Kojima, T., Mizuguchi, M. & Takanashi, K. L1₀-ordered FeNi film grown on Cu-Ni binary buffer layer. *Journal of Physics: Conference Series* 266, 012119 (2011).
- 21. Gong, M. & Ren, S. Phase Transformation-Driven Surface Reconstruction of FeNi Nanostructures. Chem. Mater. 27, 7795 (2015).
- 22. Miura, Y. The origin of perpendicular magneto-crystalline anisotropy in L1₀–FeNi under tetragonal distortion. *J. Phys.: Condens. Matter* **25**, 106005 (2013).
- 23. Sakamaki, M. & Amemiya, K. Effect of structural strain on magnetic anisotropy energy of each element in alternately layered FeNi thin films. *Phys. Rev. B* 87, 014428 (2013).
- 24. Mishin, Y., Mehl, M. J. & Papaconstantopoulos, D. A. Phase stability in the Fe–Ni system: Investigation by first-principles calculations and atomistic simulations. *Acta Materialia* 53, 4029–4041 (2005).
- 25. Byshkin, M. & Hou, M. Phase transformations and segregation in Fe-Ni alloys and nanoalloys. J Mater Sci 47, 5784-5793 (2012).
- Kovacs, A. Micromagnetic Simulations for Coercivity Improvement through Nano-Structuring of Rare-Earth Free L1₀-FeNi Magnets. IEEE Transactions on Magnetics 53(NO. 11), 7002205 (2017).

- 27. Rahman, G., Kim, I. G. & Bhadeshia, H. K. D. H. A first-principles investigation on the effects of magnetism on the Bain transformation of α -phase FeNi systems. *Journal of Appl. Phys* 111, 063503 (2012).
- 28. Bain, E. C., The Nature of Martensite, Trans. AIME, 70, pp. 25-35 (1924).
- Giannopoulos, G. et al. Large magnetic anisotropy in strained Fe/Co multilayers on AuCu and the effect of carbon doping. APL Materials 3, 041103 (2015).
- 30. Kusne, A. G. *et al.* On-the-fly machine-learning for high-throughput experiments: search for rare-earth-free permanent magnets. *Sci Rep.* **4**, 6367 (2014).
- 31. Jain, Å. *et al.* Commentary: The Materials Project: A materials genome approach to accelerating materials innovation. *APL Materials* 1, 011002 (2013).
- 32. Xiang, X. D. et al. A Combinatorial Approach to Materials Discovery. Science, 268, Issue 5218, pp. 1738-1740 (1995).
- 33. Holloway, P. H. & Vaidyanathan, P. N. Characterization of Metals and alloys, Momentum Press, LLC, 2010
- 34. Goto S. et al. Synthesis of single-phase L1₀ FeNi magnet powder by nitrogen insertion and topotactic extraction; Scientific Reports 7:13216, (2017)
- 35. International Crystal Structure Database; ICSD#:56386.
- 36. P. A. Stadelmann. JEMS EMS java version, (2004).
- 37. Barucca, G. et al. Magnetic anisotropy phase-graded A1/L1₀-FePt films on amorphous glass substrates. Materials & Design 123, 147–153 (2017).
- 38. Lim, Y. S. & Lee, J. Y. Strain-induced anisotropic Ge diffusion in SiGe/Si superlattices, *Appl. Phys. Lett.* **80**, Issue 14, 2481–2483 8 (April 2002).
- 39. Reck, R. A. & Fry, D. L. Orbital and Spin Magnetization in Fe-Co, Fe-Ni, and Ni-Co. Phys. Rev. 184, 492 (1969).
- 40. Salikhov, R. Enhanced spin-orbit coupling in tetragonally strained Fe-Co-B films. J. Phys.: Condens. Matter 29, 275802 (2017).
- 41. Farle, M. Ferromagnetic resonance of ultrathin metallic layers. Rep. Prog. Phys. 61, 755 (1998).
- 42. Salikhov, R. Magnetic properties of nanolaminated (Mo_{0.5}Mn_{0.5})₂GaC MAX phase. Journal of Appl. Phys. 121, 163904 (2017).
- 43. Spasova, M. et al. Magnetic properties of arrays of interacting Co nanocrystals. J. Magn. Magn. Mater. 240, 40-43 (2002).
- 44. O'Handley, R. C. Modern Magnetic Materials: Principles and Applications, by R. C. O'Handley (Wiley, New York, 1999).

Acknowledgements

Funding from the E.C. is acknowledged (686056-NOVAMAG and 691235-INAPEM). WAXS and XRF data were collected at SSRL, which is supported by U.S. Department of Energy, Office of Science, Office of Basic Energy Sciences under contract No. DE-ACO2-76SF00515. R.S. acknowledges funding by the Deutsche Forschungsgemeinschaft (DFG) under Grant No. SA 3095/2-1. Authors acknowledge Dr. F. Ren (SSRL, Stanford University) for the guidance in WAXS and XRF measurements and Professor G. Hadjipanayis for revising the manuscript.

Author Contributions

G.G., G.B., A.K., R.S. and G.V. wrote the manuscript. V.P., M.F., A.M. and D.N. revised the manuscript. G.G. and G.B. contributed equally as corresponding authors to the manuscript. All authors discussed the results and drew the conclusions. A.K. prepared the samples and performed the MOKE XRF and WAXS measurements, G.G conducted the XRD, E.K. the A.F.M. measurements, R.S. the F.M.R. characterization and T.E.M. experiments were conducted by G.B., M.S., G.N. and C.S. Experimental data were analyzed by G.G., G.B., A.K., R.S., S.L., M.S. and G.V.

Additional Information

Supplementary information accompanies this paper at https://doi.org/10.1038/s41598-018-34296-9.

Competing Interests: The authors declare no competing interests.

Publisher's note: Springer Nature remains neutral with regard to jurisdictional claims in published maps and institutional affiliations.

Open Access This article is licensed under a Creative Commons Attribution 4.0 International License, which permits use, sharing, adaptation, distribution and reproduction in any medium or format, as long as you give appropriate credit to the original author(s) and the source, provide a link to the Creative Commons license, and indicate if changes were made. The images or other third party material in this article are included in the article's Creative Commons license, unless indicated otherwise in a credit line to the material. If material is not included in the article's Creative Commons license and your intended use is not permitted by statutory regulation or exceeds the permitted use, you will need to obtain permission directly from the copyright holder. To view a copy of this license, visit https://creativecommons.org/licenses/by/4.0/.

© The Author(s) 2018